

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	1	(etch\$3 or pattern\$3) same (vector near polymer\$3)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/08/13 15:25
L2	80559	((etch\$3 or pattern\$3) same polymer\$3)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/08/13 14:01
L3	93	2 same (nanoparticle or nano near structure)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/08/13 15:03
L4	1	3 and payload	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/08/13 15:55
L5	139	(payload or (iron near oxide or "Fe.sub.2 O.sub.3")) same (nanoparticle or nano near structure)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/08/13 15:04
L6	116	5 and (etch\$3 or pattern\$3 or remov\$3)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/08/13 15:20
L7	2	("6346189").PN.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/08/13 15:21
L8	0	("moll-nicolas-j.in.").PN.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/08/13 15:21
L9	17	moll-nicolas-j.in.	US-PGPUB; USPAT	OR	OFF	2005/08/13 15:23
L10	46	roitman-daniel-b.in.	US-PGPUB; USPAT	OR	OFF	2005/08/13 15:23
L11	1	10 and (vector near polymer near5 payload)	US-PGPUB; USPAT	OR	OFF	2005/08/13 15:24
L12	1	lu-jennifer-q.in. and (vector near polymer near5 payload)	US-PGPUB; USPAT	OR	OFF	2005/08/13 15:25

L13	2	(etch\$3 or pattern\$3) same (poly near vinyl near ferrocene or poly near iron near acrylate or iron near diblock near polymer)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/08/13 15:48
L14	23	(etch\$3 or pattern\$3) and (poly near vinyl near ferrocene or poly near iron near acrylate or iron near diblock near polymer)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/08/13 15:48
L15	2	payload same ((nano near particle) or (nano near structure))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/08/13 15:56
L16	300	(payload or iron) and ((nano near particle) or (nano near structure))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/08/13 15:57
L17	24	16 and ((pattern\$3 or etch\$3 or remov\$3) same photoresist)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/08/13 15:58